

# Distribution of deep level defects in InGaN/GaN LEDs and their dependence on In alloying

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# Outline

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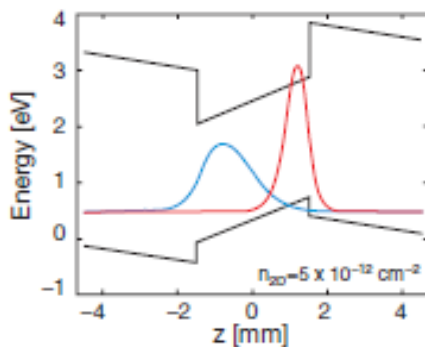
- I. Green gap for InGaN/GaN and role of deep level defects**
- II. Quantitative characterization of QW deep levels in InGaN/GaN LEDs**
- III. QW deep level defect evolution with indium alloying (*c*-plane)**
- IV. Origin of QW deep level defects**
- V. Conclusions**

# Green-gap limits InGaN/GaN LEDs and LDs

- “Green gap” persists in semi- and non-polar InGaN/GaN LEDs, LDs
  - Efficiency drops with increasing  $\lambda$
  - Not completely explained by Quantum-confined Stark Effect (QCSE)
- Suggests a contribution from defects

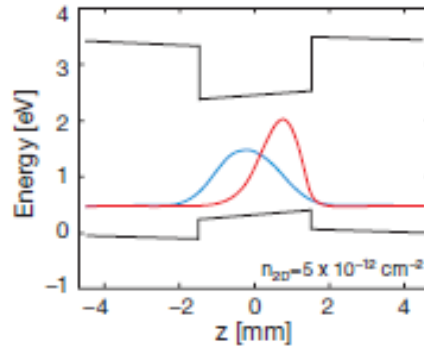
## Green gap more than QCSE

c-plane



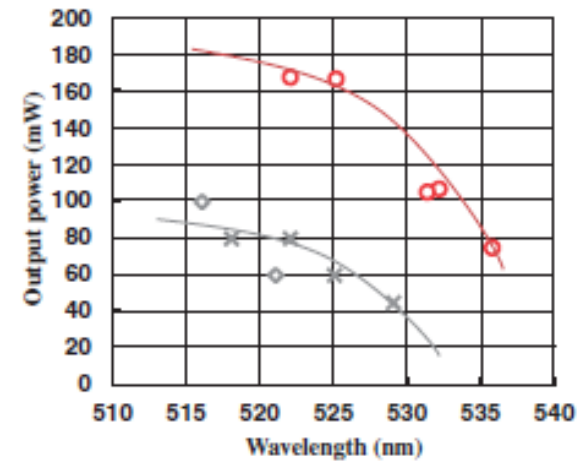
Ulrich T. Schwarz and  
Wolfgang G. Scheibenzuber

Semi-polar



Optics & Photonics News

Semi-polar LD power vs.  $\lambda$



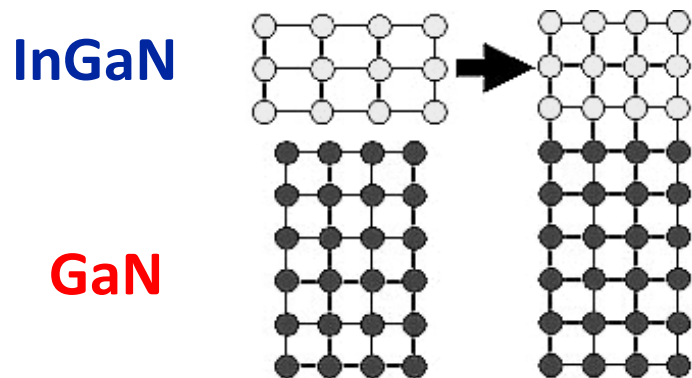
Takagi *et al.* Applied Physics Express 5 (2012) 082102

# Defects and InGaN/GaN MQWs

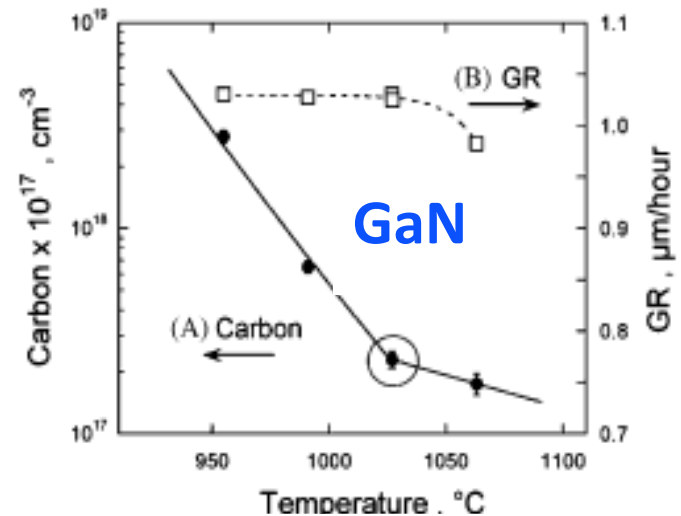
InGaN/GaN MQWs have potential for high defect density:

- Highly mis-matched epitaxy
- Heterostructures force trade-offs between growth conditions

Mis-matched epitaxy and strain



Non-ideal growth conditions

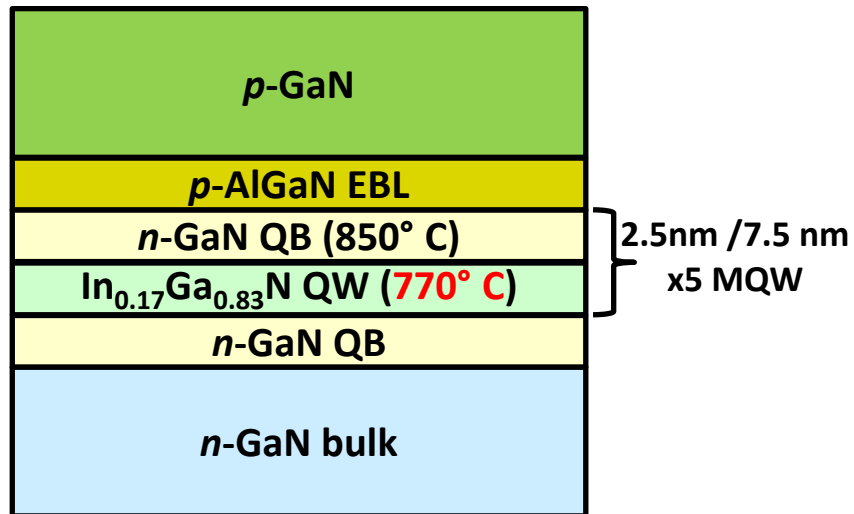


Koleske *et al.*, JCG 242 55 (2002)

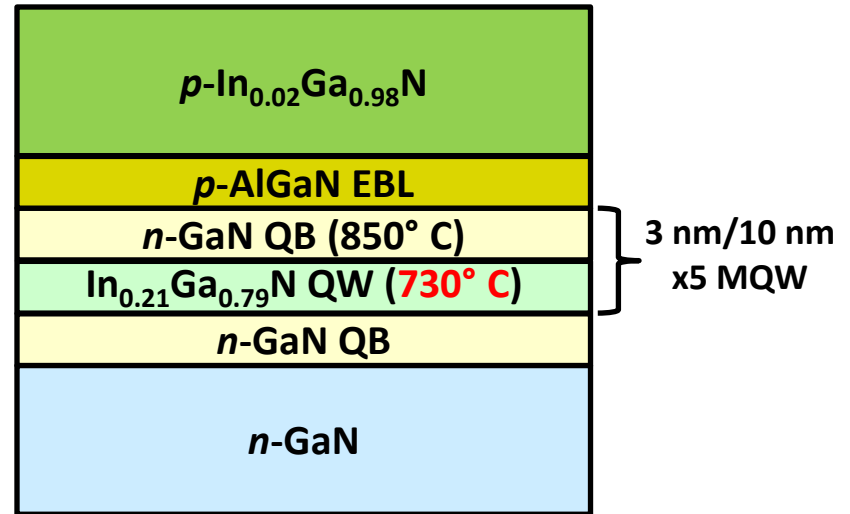
Defect formation more likely with increasing indium,  $\lambda$

# Sample description

## 450 nm InGaN/GaN LED



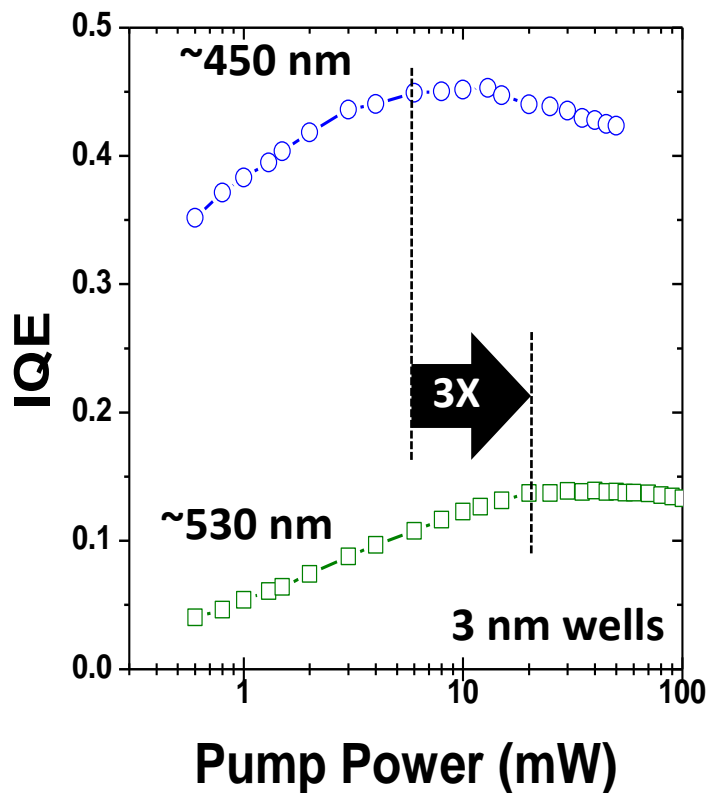
## 530 nm InGaN/GaN LED



- MOCVD-grown LEDs on  $c$ -plane
- Reduced QW  $T_g$  for green LED

# Green LED IQE indicates excess defects

## LED IQE vs. optical pump power



$$IQE = \frac{Bn^2}{An + Bn^2 + Cn^3}$$

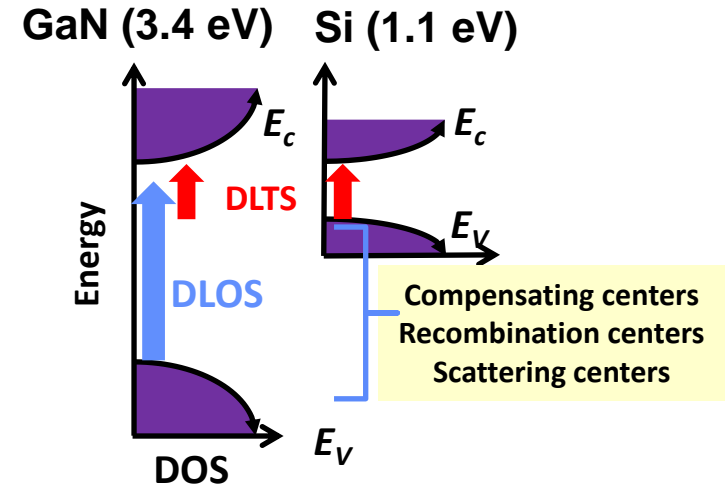
$$n_p = \sqrt{\frac{A}{C}}$$

- Peak IQE shifts to larger power with increasing indium
- Suggests additional non-radiative recombination

# Quantitative LED defect spectroscopy is difficult

**Challenge:** Wide (In)GaN band gap (2.3 – 3.4 eV)

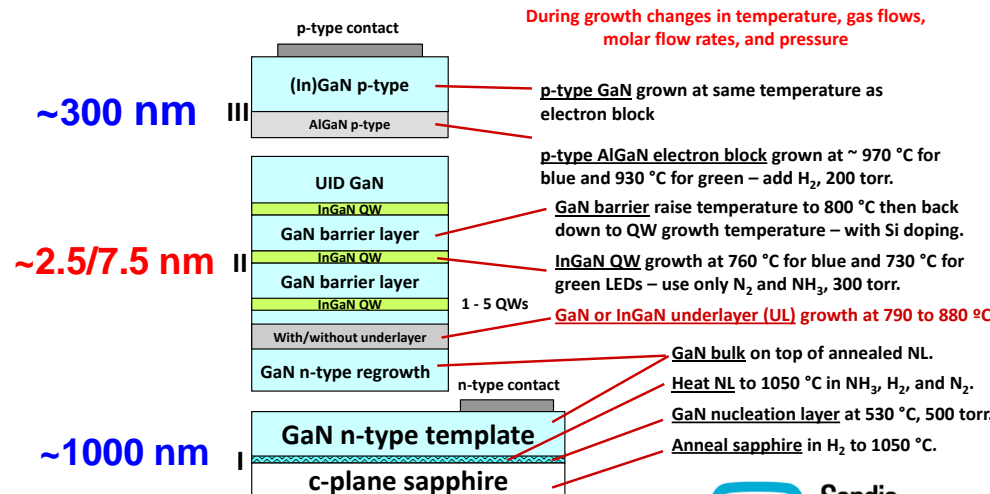
- Thermal emission rates decrease exponentially with trap energy



**Challenge:** Needle in a “haystack”

- Need nanoscale depth resolution to differentiate QW and QB defects

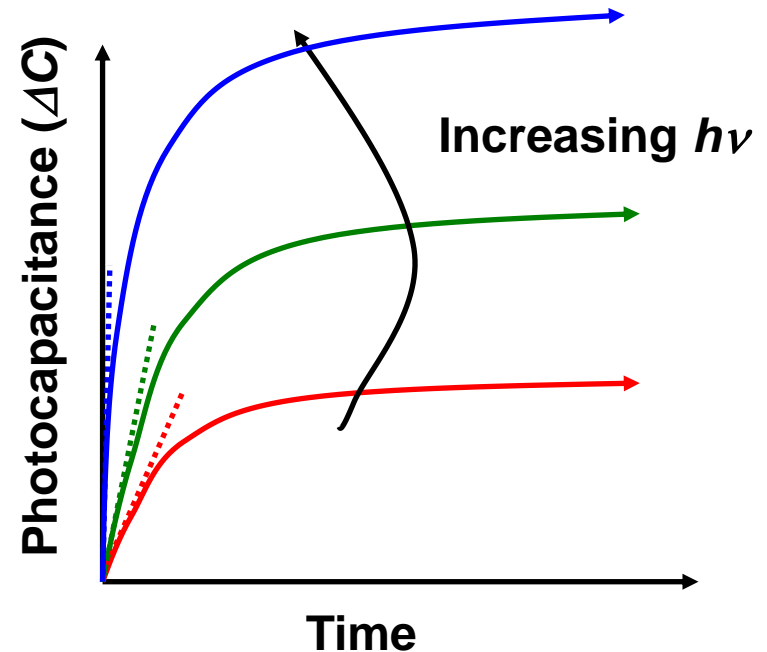
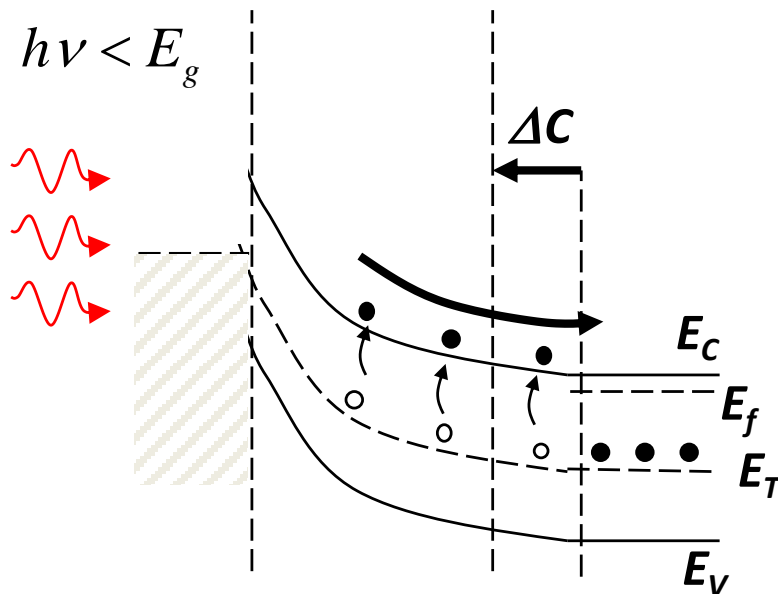
## LED design - NOT TO SCALE!



# Deep Level Optical Spectroscopy

## “Thin film” Deep Level Optical Spectroscopy (DLOS)<sup>1</sup>

- Photocapacitance technique
- Sub-band gap optical stimulation to photoionize defect levels
- Quantify non-radiative defect level energy ( $E^0$ )



- DLOS only sensitive to depleted regions

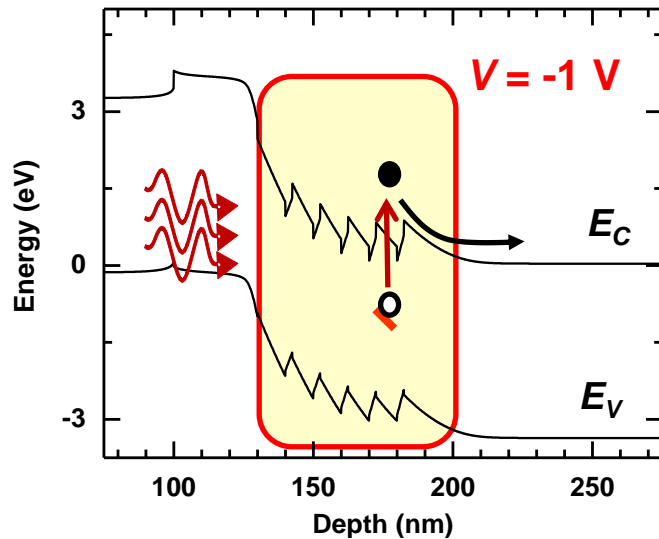
1. Chantre *et al.* PRB 23, 5335 (1981).

- Optical cross-section  $\sigma^0 = e^0/\Phi = \alpha/N_t$
- $\sigma^0(h\nu) \propto dC(t)/dt|_{t=0}$
- Fit  $\sigma^0(h\nu)$  to model for  $E^0$
- Address defect density later...



# DLOS provides depth resolution in LEDs

## LED MQW 1D-SP calculations\*

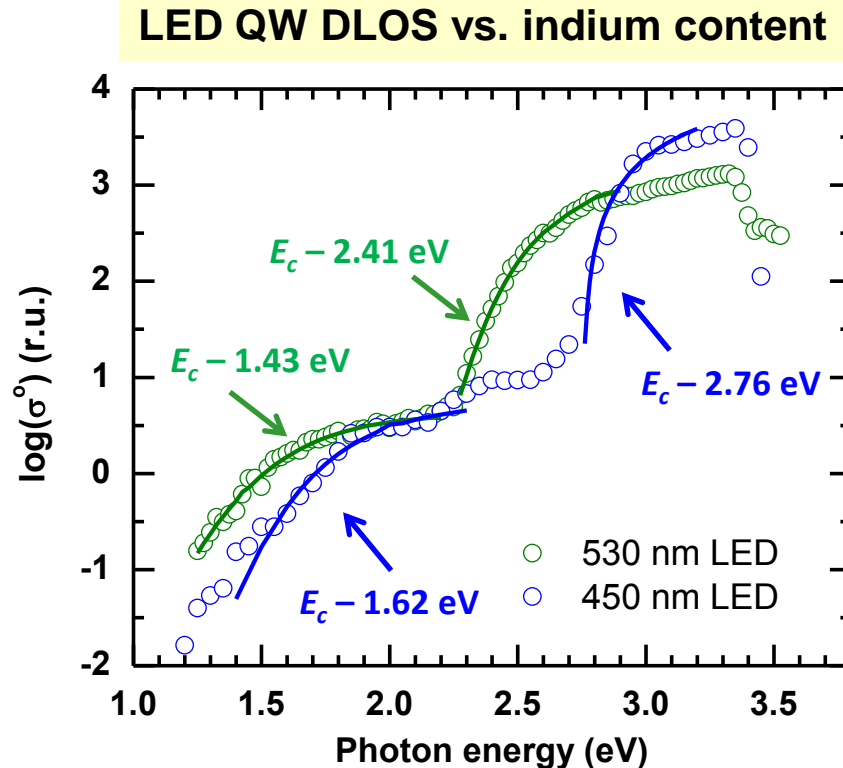


\*G. Snider UND

**$V = -1 \text{ V}$ : DLOS selective to the MQW region**

➤ Detect both InGaN QW and GaN QB defects

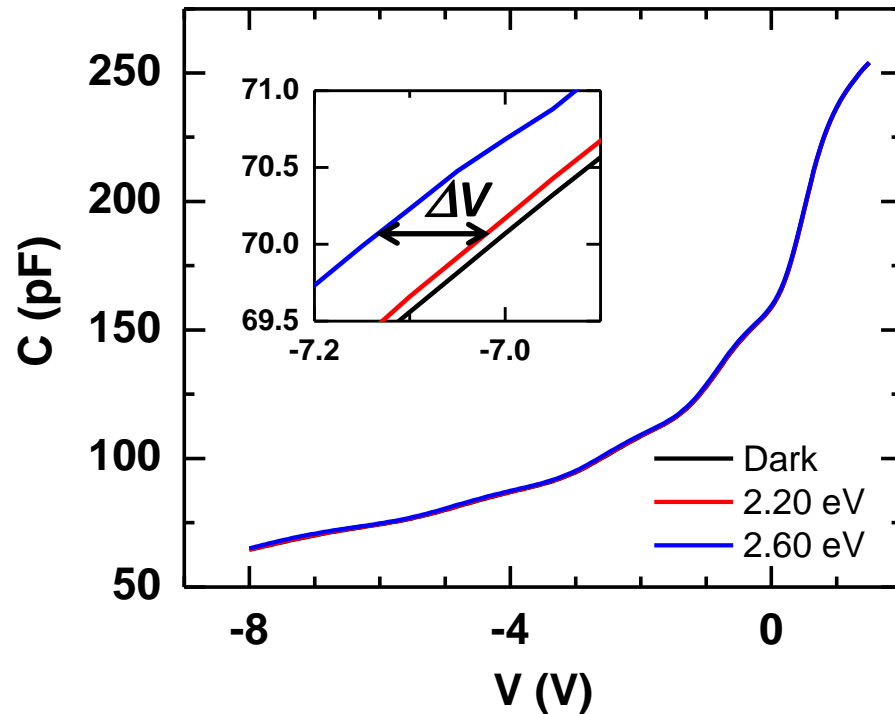
# LED QW deep level evolve with Indium content



- InGaN band edges demonstrate QW sensitivity
- Near- $E_v$  and near mid-band gap deep levels
- Identify QW defect levels from red-shift with increasing indium

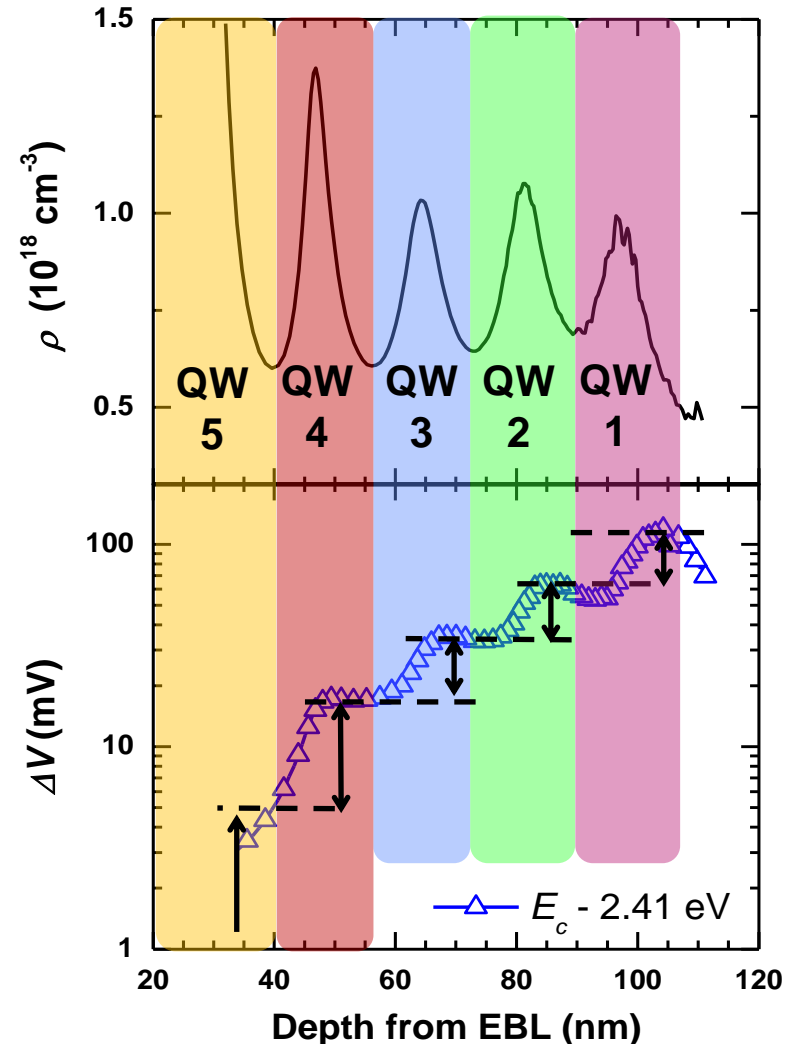
# Lighted-CV quantifies QW defect density

## Lighted C-V of 530 nm LED



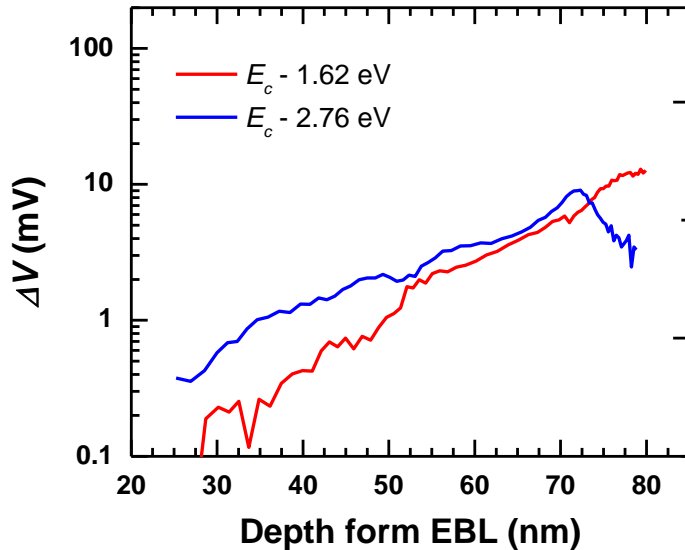
$$\Delta V = \frac{q}{\epsilon} \int_{x_1}^{x_2} x N_t dx$$

## Depth profile of MQW defects

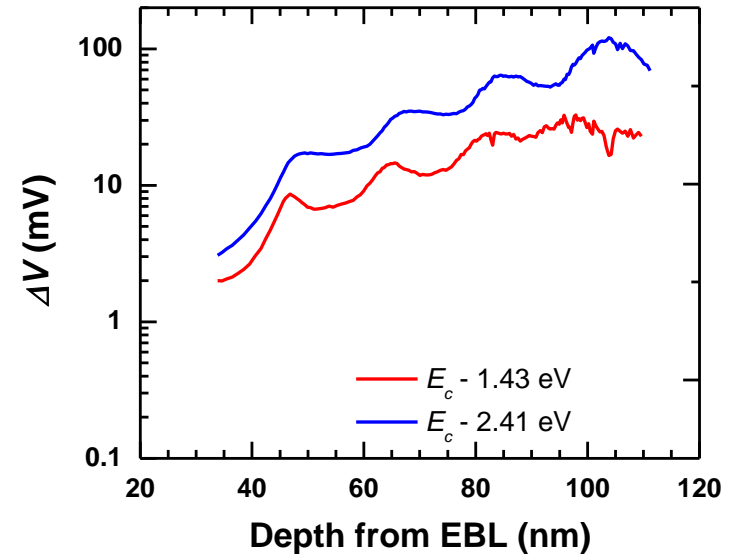


# QW deep level defect density

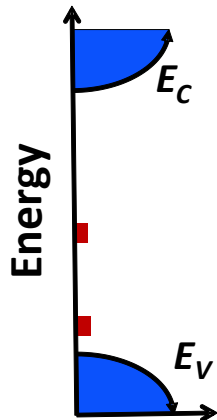
LCV of 450 LED



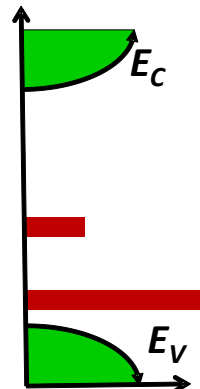
LCV of 530 LED



450 nm QW



530 nm QW

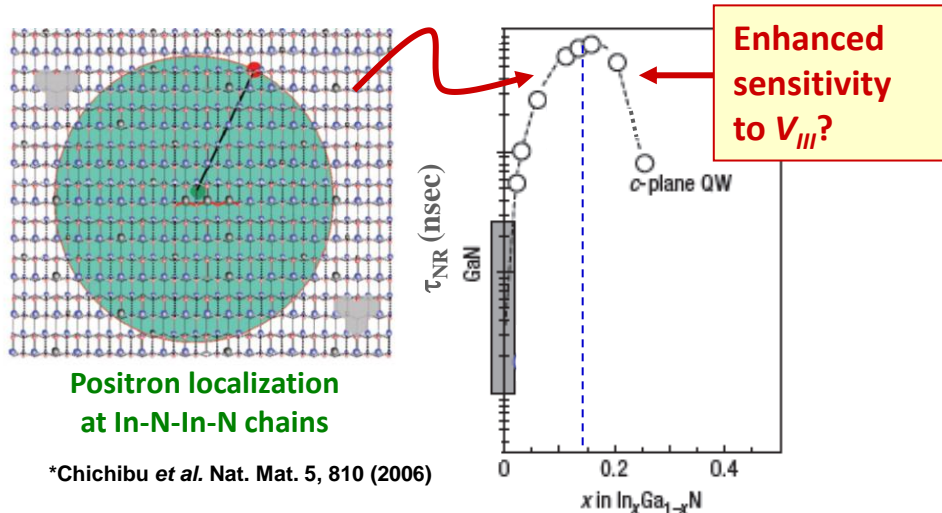


Deep level density of states

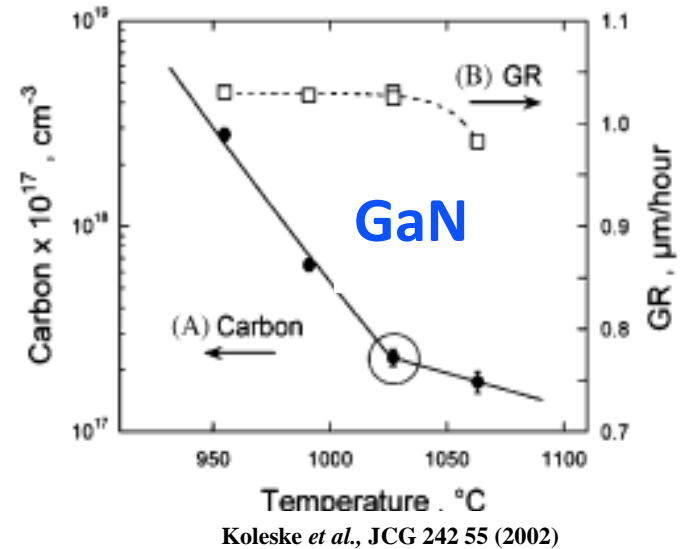
Defect Level (eV)	$N_t$ (cm <sup>-3</sup> )	$\Delta N_t$
$E_c - 1.62$	4.1e15	4.4x
$E_c - 1.43$	1.8e16	
$E_c - 2.76$	4.4e15	13x
$E_c - 2.43$	5.5e16	

# Possible origin of QW defects – $V_{III}$ and/or carbon

$V_{III}$  density increases with indium



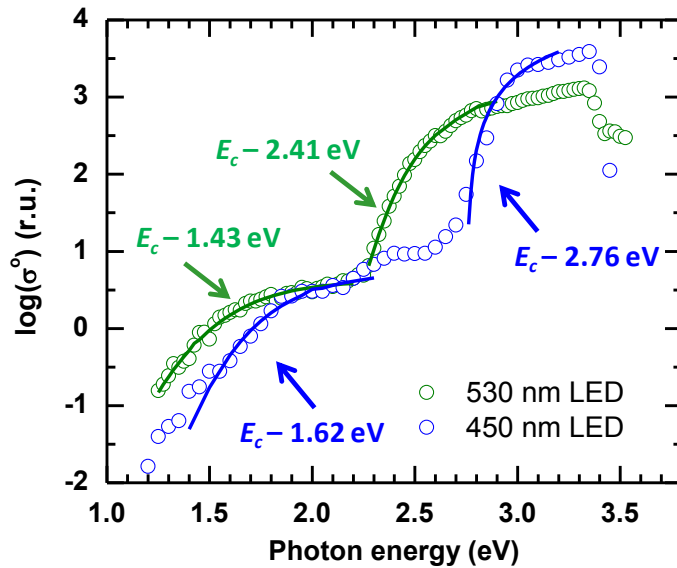
[C] increases with lower  $T_g$



- $V_{III}$  and carbon are well known non-radiative recombination centers in GaN
- PAS and PL studies\* show that  $[V_{III}]$  increases and  $\tau_{NR}$  decreases with indium
- Reasonable that carbon also incorporation increases with reduced QW  $T_g$

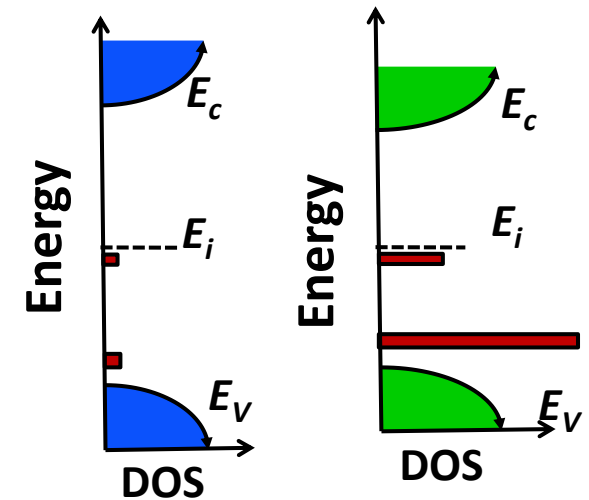
# Conclusions

LED QW DLOS vs. indium content

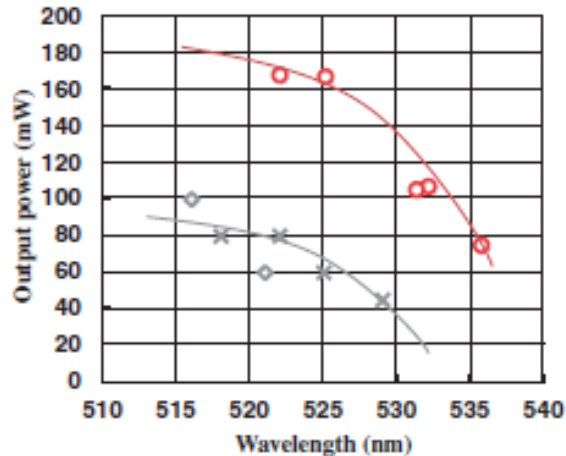


Defect density

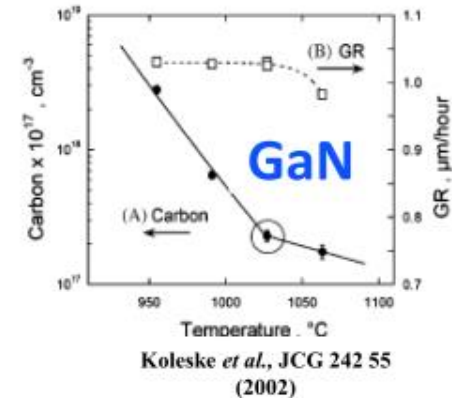
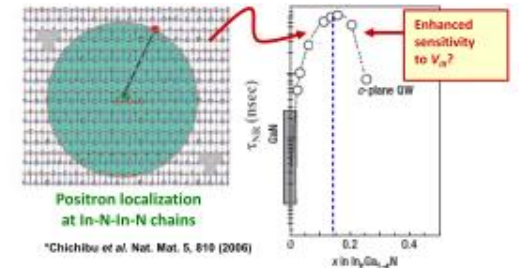
$\text{In}_{0.14}\text{Ga}_{0.86}\text{N}$  QW  $\text{In}_{0.22}\text{Ga}_{0.78}\text{N}$  QW



Semi-polar LD power vs.  $\lambda$



Defect density



Takagi *et al.* Applied Physics Express 5 (2012) 082102

Koleske *et al.*, JCG 242 55 (2002)